

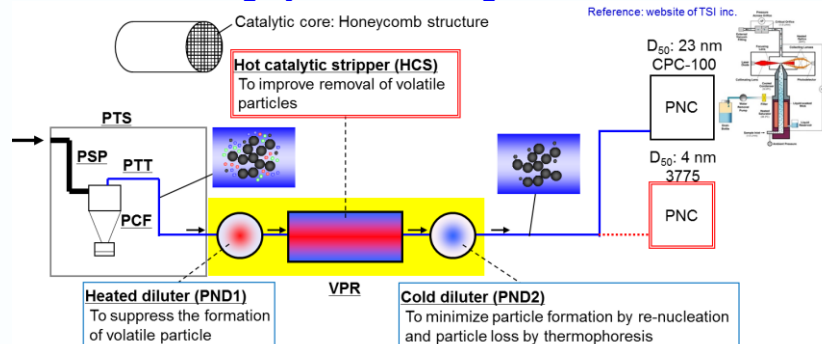
# Performance of (Sub-23 nm) Particle Counting System Utilizing a Commercially Available PMP System

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## Configuration of Sub-23 nm PN Measurement System

### Solid Particle Counting System Including Sub-23 nm Particles

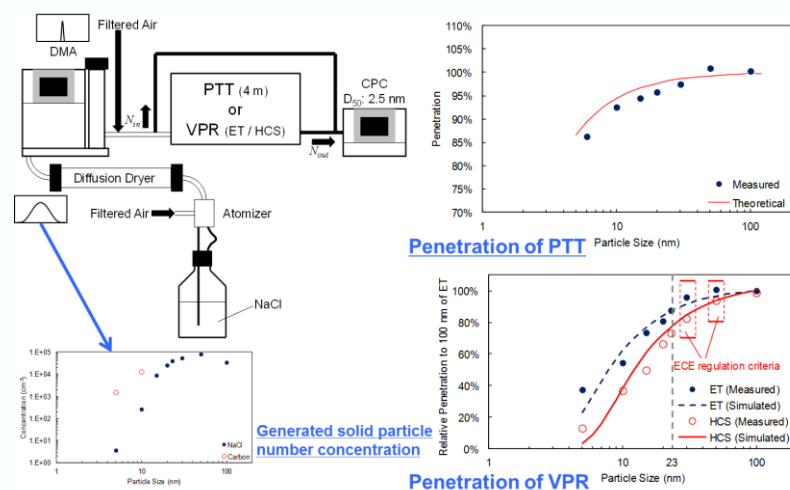


- ET was replaced by HCS in order to improve volatile removal performance
  - Oxidation catalyst can eliminate HCs by the oxidation ability
  - Absorption of sulfates
- PNC with  $D_{50}$  at 4 nm in parallel of PMP PNC ( $D_{50} = 23$  nm)

### Difficulties of Sub-23 nm Measurement

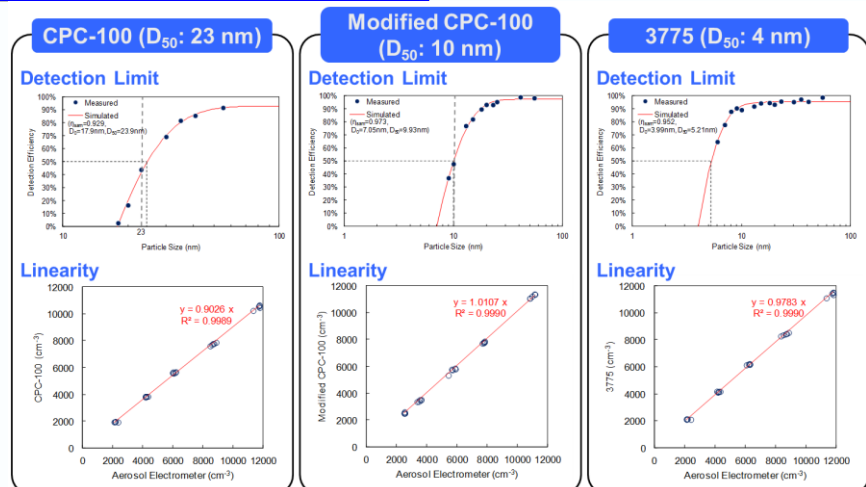
- Calibration of particle number counters
- Re-nucleation of volatile particles
  - High concentration volatile particles may cause re-nucleation at the VPR outlet
- Reduced solid particle penetration due to higher diffusion losses
  - VPR should be evaluated by sub-23 nm solid particles
  - The losses at PTT are still negligible?

## Detection Efficiencies of PNCs



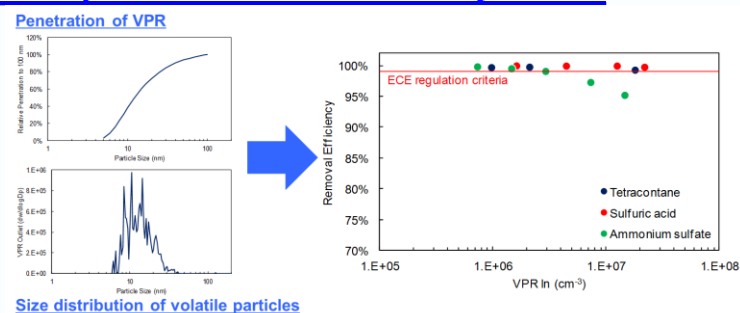
- It is challenging to generate sub-10 nm solid particles
- Lower penetrations were observed by smaller particles because of diffusion losses
- PTT penetration was still higher than 85% at 5 nm
- Penetration of VPR with the HCS was lower and more size dependent than the ET
  - Cause of measurement error of sub-23 nm particles

## Detection Efficiencies of PNCs



- $D_{50}$  of each PNC was at the specified particle diameters
- It is quite challenging to generate sub-10 nm poly-alpha-olefin particles
- $D_{50}$  of PMP PNC was successfully adjusted down to 10 nm
  - Linearity should be verified when  $D_{50}$  is changed

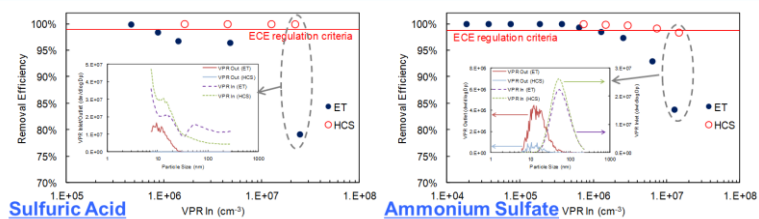
## Cause of Improved Removal Efficiency of HCS



- Volatile particle removal performance can be improved by the reduced VPR penetration
  - Removal efficiencies were corrected by VPR penetration and size distribution of residual volatile particles in order to clarify the cause of the improvement
    - Slightly decreased efficiency due to large amount of sub-23 nm volatile particles at VPR outlet
    - Removal efficiency of HCS is still higher than ET
  - Improved performance was not caused mainly by diffusion losses of VPR

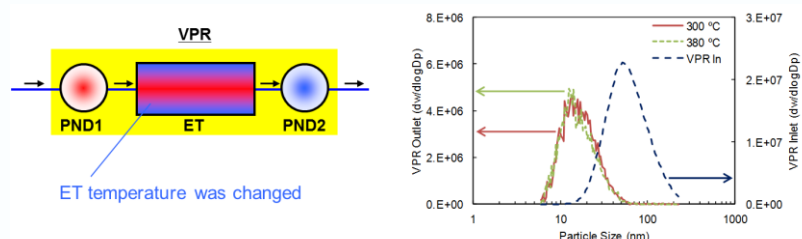
## Volatile Particle Removal Performance of VPR

### Comparison of Performance between ET and HCS



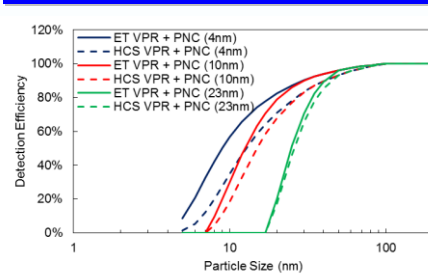
- The HCS has higher performance than ET
- Sizes of residual particles are mainly below 23 nm
  - Cause of high biases to sub-23 nm solid particle measurement

### Cause of Residual Particles



- Almost same removal efficiencies and size distributions were observed
  - Residual particles were generated mainly by the re-nucleation of high volatile fractions

## Overall Detection Efficiency of the System



- Overall detection efficiencies of the system were estimated by verified PNC detection efficiencies and penetrations of VPR and PTT
- Difference between HCS and ET VPRs was significant with PNC which has smaller  $D_{50}$ 
  - VPR penetration is dominant to the overall detection efficiency of the solid particle number measurement system

## Conclusions

- The PTT length should be as short as possible in order to prevent particle losses of tiny nanoparticles for sub-23 nm particle measurement
- The higher reduction efficiencies of the HCS against high volatile particle concentration were observed compared with the conventional ET
- Penetration of the HCS tends to be lower than the ET because of the diffusion losses
- Establishment of particle generation procedures for PNC and VPR calibration are necessary because it is quite challenging to generate enough high concentration calibration particles

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